

Second Semester M. E. Examination  
**RF AND MICROWAVE CIRCUIT DESIGN**

2 ENTC 4

P. Pages : 4

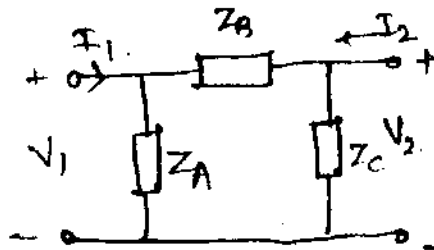
Time : Three Hours ]

[ Max. Marks : 80

- Note :** (1) Separate answer book must be used for each section in the subject Geology, Engineering material of civil branch and Separate answer book must be used for Section A and B in Pharmacy and Cosmetic Tech.
- (2) Answer **Three** questions from Section A and **Three** questions from Section B.
- (3) Due credit will be given to neatness and adequate dimensions.
- (4) Assume suitable data wherever necessary.
- (5) Illustrate your answer wherever necessary with the help of neat sketches.
- (6) Use pen of Blue/Black ink/refill only for writing the answer book.

**SECTION A**

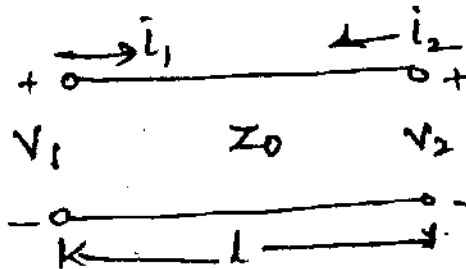
1. (a) State and prove unity property of [S] matrix. 7
- (b) Compute Z-parameters for the Pi n/w shown in fig.1



7

**OR**

2. (a) Find the [A B C D] matrix for a lossless transmission line of length  $l$  and characteristic impedance  $Z_0$  as shown below.



7

(b) Derive the condition of reciprocal and lossless network for S-parameters.

7

3. (a) Using Smith chart design all possible configuration of discrete two element matching network that match the source impedance  $Z_s = (50 + j25)\Omega$  to load  $Z_L = (25 - j50)\Omega$ . Assume a characteristic impedance  $Z_0 = 50\Omega$  and an operating frequency of 2 GHz. 13

OR

4. (a) Design a T-type matching network that transforms load impedance  $Z_L = (60 - j30)\Omega$  into  $Z_{in} = (10 + j20)\Omega$  input impedance that has a maximum nodal quality factor of 3, Compute the values for the matching network components assuming that matching is required at  $f = 1$  GHz. 13

5. (a) Explain the following terms related to RF transistor amplifier.

(i) Transducer power gain.

(ii) Unilateral power gain.

(iii) Operating power gain. 6

- (b) Explain in brief constant VSWR circle. 7

OR

6. (a) Design a 18dB single stage MESFET amplifier operated at 5.7 GHz has following S-parameters.

$$S_{11} = 0.5 \angle -60^\circ ; S_{12} = 0.02 \angle 0^\circ$$

$$S_{21} = 6.5 \angle 115^\circ ; S_{22} = 0.6 \angle -35^\circ$$

(a) Determine if the circuit is unconditionally stable

(b) Find Maximum power gain under optimal choice of reflection coefficient, assuming unilateral design ( $S_{12} = 0$ )

(c) Adjust the load coefficient such that the desired gain realized using concept of constant gain circle. 13

## SECTION B

7. (a) Explain Negative resistance oscillator circuit in detail. 6
- (b) A crystal is characterized by the parameters  $L_q = 0.1 \text{ H}$ ,  $R_q = 25 \Omega$ ,  $C_q = 0.3 \text{ PF}$  and  $C_o = 1 \text{ PF}$ . Determine series and parallel resonance frequencies. 7

OR

8. (a) Explain single ended mixer design approach. 6
- (b) For a 280 MHz oscillation frequency a Colpitts BJT oscillator in CE configuration has to be designed. For a bias point of  $V_{CE} = 3\text{V}$  and  $I_C = 3\text{mA}$ , the following circuit parameters are given at room temperature of  $25^\circ\text{C}$ .  
 $C_{BC} = 0.1 \text{ PF}$  ;  $V_{BE} = 2 \text{ k}\Omega$   
 $V_{CE} = 10 \text{ k}\Omega$  ;  $C_{BE} = 100 \text{ pf}$ . 7
9. (a) Explain the even and odd mode analysis of coupled microstriplines. 7
- (b) Which methods are used for the analysis of microstrip lines ? Explain hybrid mode analysis method. 7

OR

10. (a) A gold parallel strip line has the following parameters :—  
 Relative dielectric constant of polyethylene  $\epsilon_{rd} = 2.25$   
 Strip width  $w = 25 \text{ mm}$   
 separation distance  $d = 5 \text{ mm}$   
 Calculate :—
- (a) Characteristics impedance of strip line.
- (b) Strip-line capacitance.
- (c) Strip-line inductance.
- (d) Phase velocity. 7
- (b) Explain the losses in microstriplines. 7

11. (a) Discuss in brief Monolithic Microwave Integrated circuits (MMIC) 7
- (b) Explain the following techniques used in fabrication of MMICs.
- (i) Diffusion and ion implantation.
  - (ii) Oxidation and film deposition.
  - (iii) Epitaxial growth
  - (iv) Lithography
  - (v) Etching and photoresist.
  - (vi) Deposition. 6

OR

12. (a) Explain thin film formation in MMIC. 6
- (b) List the basic properties provided by ideal conductor, dielectric and resistive materials used in MMIC. 7

